

Abstract

# Heterogeneous Integration of Metal Oxides— Towards a CMOS Based Multi Gas Sensor Device <sup>†</sup>

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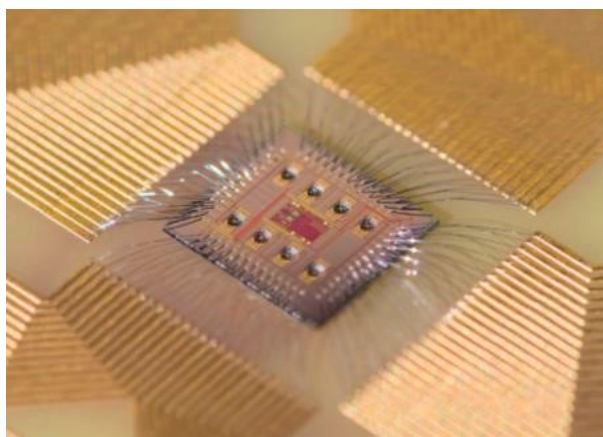
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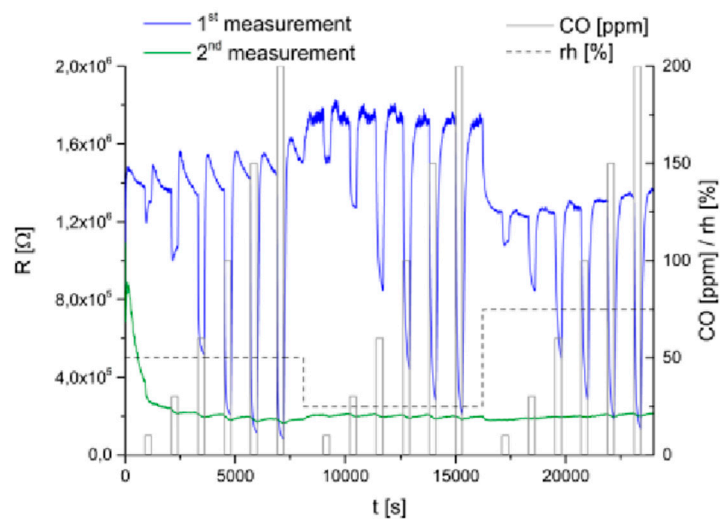
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A worldwide unique CMOS based chemical sensor device comprising an array of 8 microhotplates ( $\mu$ hps) for a total of 16 chemical sensors has been fabricated (Figure 1). Ultrathin (50 nm) SnO<sub>2</sub> films have been heterogeneously integrated on the device by spray pyrolysis technology, photolithography and etching. Subsequently the SnO<sub>2</sub> films are functionalized with metallic nanoparticles (NPs) such as Au, Pt, AuPd, or NiPt in order to improve sensitivity and selectivity. Figure 2 shows the strongly improved response of a NiPt-functionalized SnO<sub>2</sub> sensor towards carbon monoxide (10–200 ppm, 25–75% rh): at an operation temperature of only 150 °C the sensor exhibits a response of more than 90%. Presently different metal oxide films (SnO<sub>2</sub>, ZnO, CuO) additionally functionalized with NPs are processed on the  $\mu$ hp-array chip. This is the approach of choice for realization of a fully CMOS integrated multi-gas sensor device.



**Figure 1.** Chemical sensor device comprising an array of 8  $\mu$ hps for a total of 16 sensors.



**Figure 2.** Response of SnO<sub>2</sub> thin film sensor, functionalized with NiPt-NPs towards CO.

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